

***Supplementary Information***

**Strong near-infrared nonlinear optical response in nanocrystalline TiN  
for pulse generation**

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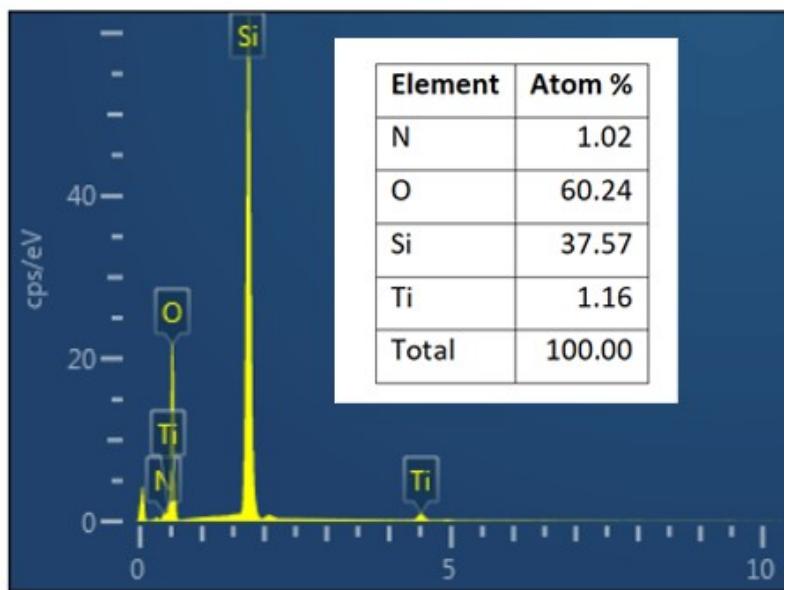
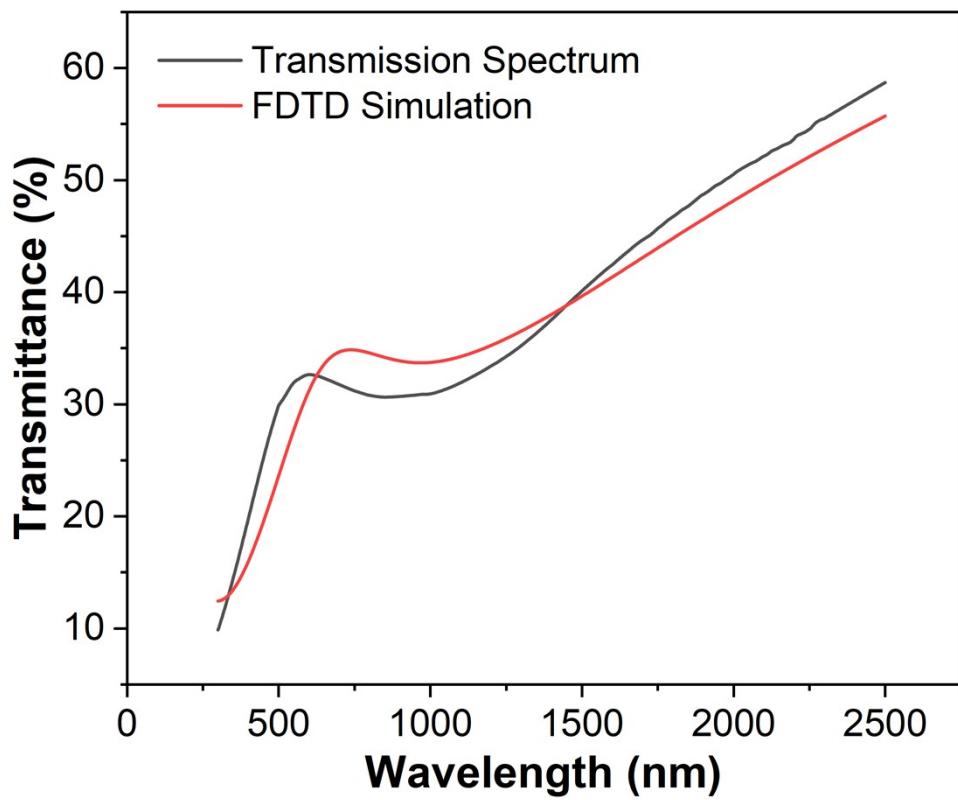


Figure S1: Energy dispersive X-ray spectrum of the sputtered nc-TiN.



*Figure S2: Comparison of FDTD-simulated and experimental transmission spectra of the nc-TiN film.*

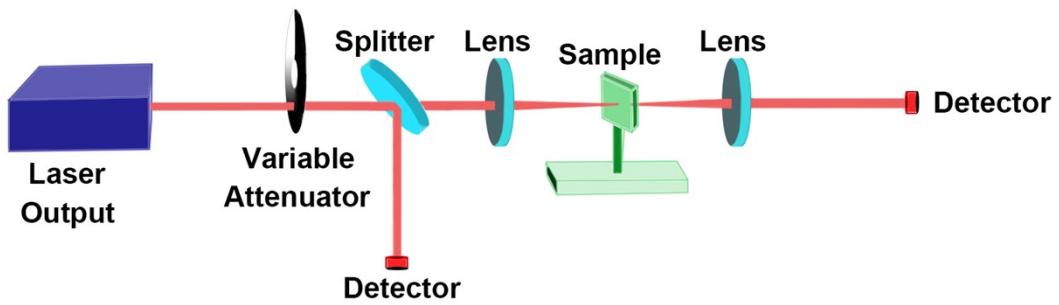


Figure S3: Schematic of the open-aperture Z-scan setup.

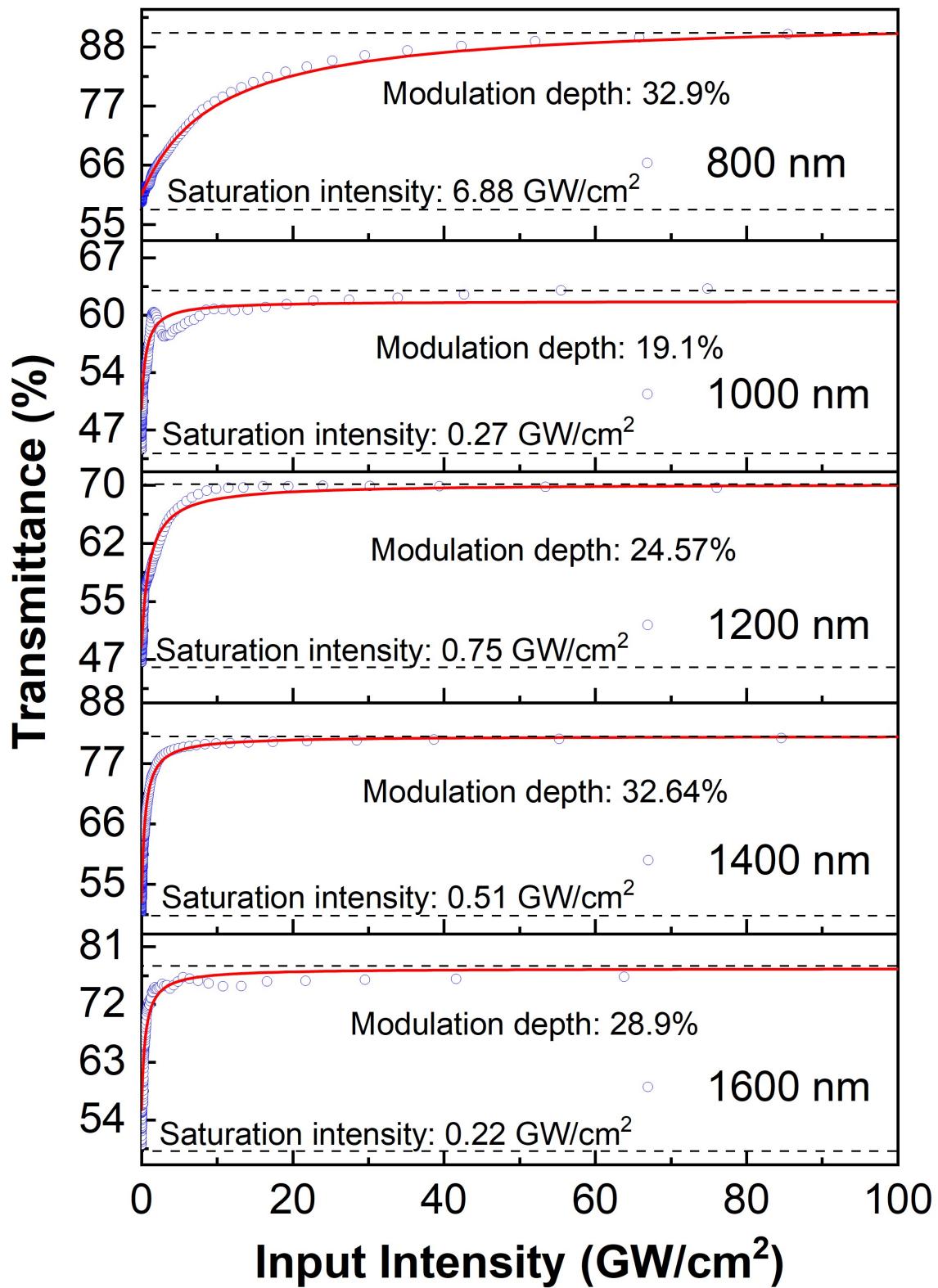


Figure S4: Modulation depth at different wavelengths.

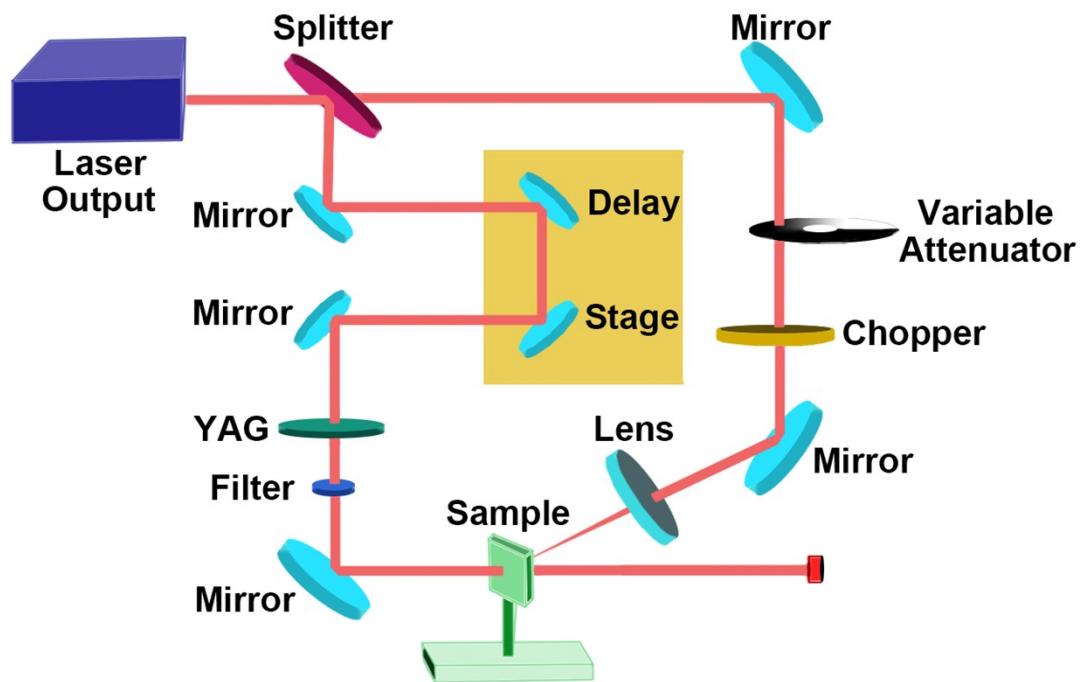


Figure S5: Schematic of the pump-probe set-up for the measurement of transient absorption spectrum.

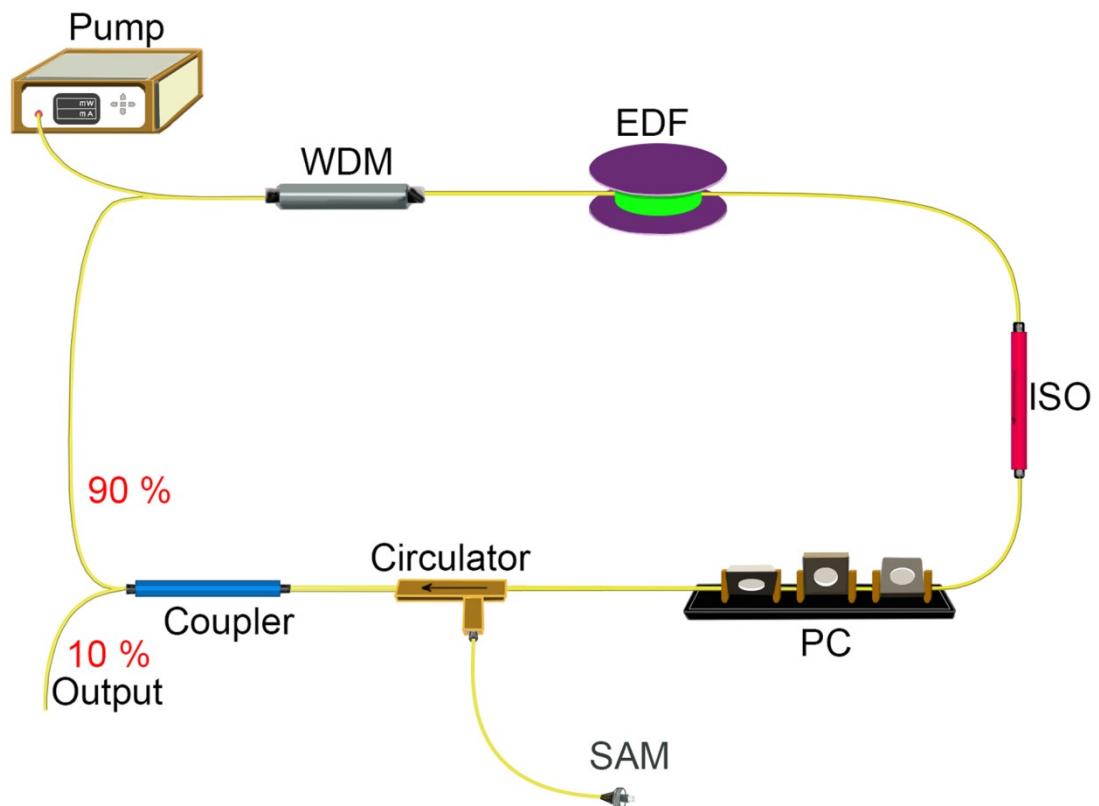


Figure S6: Schematic illustration of the fiber laser cavity employing a reflective saturable absorber based on nc-TiN.

*Table S1: Comparison of nonlinear optical parameters of several typical SA materials*

Material	Measurement	Nonlinear absorption		Saturable intensity	Modulation depth	Reference
		wavelength	coefficient( $\beta$ )			
Monolayer graphene	1550 nm	-100 cm/GW	<0.06 GW/cm <sup>2</sup>	<1.5%		1,2
Mo <sub>2</sub> C (Thickness ~15 nm)	1550 nm	-9x10 <sup>3</sup> cm/GW	0.18 GW/cm <sup>2</sup>	8.6%		3
Pristine MoO <sub>3</sub> nanosheets	800 nm	-16.74 cm/GW	20.77 GW/cm <sup>2</sup>	19.31%		4
Plasmonic MoO <sub>3</sub> nanosheets	800 nm	-33.24 cm/GW	21.94 GW/cm <sup>2</sup>	34.96%		4
Black phosphorus	1550 nm	-0.15x10 <sup>-3</sup> cm/GW				5
MoS <sub>2</sub>	800 nm	-4.6x10 <sup>-3</sup> cm/GW				6
ITO NCs	1500 nm	-51.4 cm/GW				7
TiN NCs	1550 nm	-37.1 cm/GW	125 GW/cm <sup>2</sup>	10.77%		8
Au NPs embedded LiNbO <sub>3</sub> crystal	1064 nm	-24.2 cm/GW	98.14 GW/cm <sup>2</sup>			9
nc-TiN film	1550 nm	-35.07 cm/GW	4.26 GW/cm <sup>2</sup>	16.7%		This work

*Table S2: Performance summary of mode-locked lasers based on typical SA materials.*

Material	Center wavelength	3-dB bandwidth	Repetition rate	Output power	Reference
Monolayer graphene	1559 nm	5.24 nm	19.9 MHz	22 mW	10
ITO	1558 nm	0.27 nm	1.96 MHz		11
Sb <sub>2</sub> Te <sub>3</sub>	1565 nm	30 nm	22.32 MHz	1 mW	12
Bi <sub>2</sub> Se <sub>3</sub>	1558 nm	4.3 nm	12.5 MHz	1.8 mW	13
Bi <sub>2</sub> Te <sub>3</sub>	1556 nm	4.5 nm	14.07 MHz	1.3 mW	14
MoS <sub>2</sub>	1569 nm	2.6 nm	8.288 MHz	5.1 mW	15
MoSe <sub>2</sub>	1556 nm	5.4 nm	15.38 MHz	0.23 mW	16
Black phosphorus	1561 nm	6.4 nm	6.88 MHz	5.1 mW	17
nc-TiN film	1559 nm	1.8 nm	5.0 MHz	13.8 mW	This work

## References

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